

Amendments to the Claims:

Please delete claims 1 to 9 and add claim 10 to 22 as set forth hereinafter.

Listing of Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

1. to 9. (cancelled)

10. (New) Cantilever assembly for scanning a sample, comprising a cantilever having a cantilever tip, the cantilever being mounted to a rigid support and being provided on its back side facing away from the sample with an area of a high reflectance material, this area having a boundary sloping towards said support, wherein extensions (c,  $\Delta c$ ) of the area and the boundary towards said support fulfill the condition

$$c/\Delta c \geq 1,$$

wherein

c denotes an extension of the area of the high reflectance material in direction towards the support, and

$\Delta c$  denotes an extension of the sloped boundary of the area of the high reflectance material in direction towards the support.

11. (New) Cantilever assembly according to claim 10, wherein the length of the cantilever is in the range of 1  $\mu\text{m}$  to 100  $\mu\text{m}$ , and wherein the extension (c) of the area of the high reflectance material towards the support is in the range of 0.5  $\mu\text{m}$  to 10  $\mu\text{m}$ .

12. (New) Cantilever assembly according to claim 11, wherein the length of the cantilever is in the range of 3  $\mu\text{m}$  to 20  $\mu\text{m}$ .

13. (New) Cantilever assembly according to claim 11, wherein the extension (c) of the area of the high reflectance material towards the support is in the range of 1  $\mu\text{m}$  to 6  $\mu\text{m}$ .

14. (New) Cantilever assembly according to claim 10, wherein the support is provided with a sharp edge that is located a distance (l) from the back side of the cantilever tip, the distance (l) being determined such that during application of the high reflectance material the area on the back side of the cantilever tip and the sloping boundary are formed.

15. (New) Cantilever assembly according to claim 11, wherein the support is provided with a sharp edge that is located a distance (l) from the back side of the cantilever tip, the distance (l) being determined such that during application of the high reflectance material the area on the back side of the cantilever tip and the sloping boundary are formed.

16. (New) Cantilever assembly according to claim 10, wherein the support further comprises a guidance and calibration structure for guiding and calibrating an optical tracking system in focusing on the area of the high reflectance material.

17. (New) Cantilever assembly according to claim 10, wherein that portion of the support to which the cantilever is attached has a recessed shape, the said recessed shape narrowing in direction towards the cantilever.

18. (New) Cantilever assembly according to claim 17, wherein the recessed shape is partly-octagonal.

19. (New) Cantilever assembly according to claim 10, wherein the cantilever comprises

a step-like portion which is arranged near that end of the cantilever which is attached to the support, the said step-like portion substantially increasing a thickness of the cantilever on a front side of the cantilever.

20. (New) Cantilever assembly according to claim 10, wherein said support comprises at least two steps, the steps being provided with an edge, wherein the edge of the first step is located such that during application of the high reflectance material the area on the back side of the cantilever tip and the sloping boundary are formed and wherein the edge of the second step is located such that it does not obstruct application of the high reflectance material.

21. (New) Process for manufacturing a cantilever assembly for scanning a sample, said cantilever having a cantilever tip, the cantilever being mounted to a rigid support and being provided on its back side facing away from the sample with an area of a high reflectance material, this area having a boundary sloping towards said support, wherein extensions (c,  $\Delta c$ ) of the area and the boundary towards said support fulfill the condition

$$c/\Delta c \geq 1,$$

wherein

c denotes an extension of the area of the high reflectance material in direction towards the support, and

$\Delta c$  denotes an extension of the sloped boundary of the area of the high reflectance material in direction towards the support, said process comprising applying from a source (S) of a high reflectance material the area of the high reflectance material and the sloping boundary to the back side of the cantilever tip, wherein a sharp edge of the support of the cantilever assembly is used in order to limit the extensions (c,  $\Delta c$ ) of the area and of the boundary towards the support.

22. (New) Process according to claim 21, wherein the edge of the support is located at

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a distance from the area on the back side of cantilever tip and wherein the source (S) of the high reflectance material is arranged at a distance (L) from the edge of the support and has an opening having a diameter (d), through which the high reflectance material is applied, and wherein the distance (l) from the area on the back side of cantilever tip and the edge of the support and a distance (L) from the source to the edge of the support are determined such, that

$$\Delta c / l = d / L$$

wherein

$\Delta c$  denotes the extension of the boundary of the area of the high reflectance material towards the support

l denotes a distance of the edge of the support from the area of the high reflectance material,

d denotes a diameter of an opening of the source (S) through which the high reflectance material is applied,

and

L denotes a distance between the source (S) and the edge of the support.